

Title (en)
APPARATUS AND METHOD FOR MEASURING A SUBSTRATE

Title (de)
VORRICHTUNG UND VERFAHREN ZUR VERMESSUNG EINES SUBSTRATS

Title (fr)
APPAREIL ET PROCÉDÉ DE MESURE D'UN SUBSTRAT

Publication
EP 4065957 A1 20221005 (DE)

Application
EP 19813462 A 20191128

Priority
EP 2019082881 W 20191128

Abstract (en)
[origin: WO2021104631A1] The invention relates to a method for measuring a multilayer substrate (1,1',1"), in particular having at least one structure (7, 7', 7", 7"', 7IV, 7V) of critical dimensions, in particular having a surface structure (7, 7', 7", 7"', 7IV, 7V) of critical dimensions, characterized in that the method comprises at least the following steps, in particular the following sequence of steps: producing (110) the substrate (1,1',1") having multiple layers (2, 3, 4, 5, 6, 6', 6"), in particular having a structure (7, 7', 7", 7"', 7IV, 7V), in particular having a structure (7, 7', 7", 7"', 7IV, 7V) on a surface (6o, 6'o, 6"o) of a top layer (6,6',6"), the dimensions of the layers and in particular of the structures being known, measuring (120) the substrate (1,1',1"), and in particular the structure (7, 7', 7", 7"', 7IV, 7V), by way of at least one measuring technique, generating (130) a simulation of the substrate by means of the results obtained by measuring the substrate (1,1',1"), comparing (140) the measurement results with simulation results originating from the simulation of the substrate (1,1',1"), optimizing the simulation (130) and again generating (130) a simulation of the substrate by means of the results obtained by measuring the substrate (1,1',1") if the measurement results deviate from the simulation results, or calculating (150) parameters of other substrates if the measurement results correspond to the simulation results.

IPC 8 full level
G01N 21/21 (2006.01); **G01B 11/02** (2006.01); **G03F 7/20** (2006.01)

CPC (source: CN EP KR US)
G01B 11/02 (2013.01 - CN); **G01B 11/065** (2013.01 - EP KR); **G01N 21/211** (2013.01 - CN KR US); **G01N 21/9501** (2013.01 - US); **G03F 7/70625** (2013.01 - CN EP KR); **G06F 30/20** (2020.01 - US); **G01B 2210/56** (2013.01 - EP KR); **G01N 21/25** (2013.01 - US); **G01N 2021/213** (2013.01 - KR); **G01N 2201/06113** (2013.01 - US)

Designated contracting state (EPC)
AL AT BE BG CH CY CZ DE DK EE ES FI FR GB GR HR HU IE IS IT LI LT LU LV MC MK MT NL NO PL PT RO RS SE SI SK SM TR

Designated extension state (EPC)
BA ME

DOCDB simple family (publication)
WO 2021104631 A1 20210603; CN 114616455 A 20220610; EP 4065957 A1 20221005; JP 2023509816 A 20230310; KR 20220103713 A 20220722; TW 202127005 A 20210716; US 2022390356 A1 20221208

DOCDB simple family (application)
EP 2019082881 W 20191128; CN 201980102109 A 20191128; EP 19813462 A 20191128; JP 2022526364 A 20191128; KR 20227015559 A 20191128; TW 109139807 A 20201113; US 201917774612 A 20191128